

# **DARE+**

Design Against Radiation Effects (Digital) Cell Libraries

Jupiter Icy Moons Explorer (JUICE)
Instruments Workshop
9 November 2011



### Objectives (1/2)

Provide a suitable and mixed-signal capable microelectronic technology for platform and payload elements of S/C on Jovian missions.

Increase and demonstrate the maturity of the existing DARE 180 nm library for applications in very harsh radiation environments up to 1 Mrad TID (Si).



## Objectives (2/2)

- Create currently missing library elements.
- Fix known issues.
- Create standard packaging solutions.
- Design, manufacture and evaluate a test vehicle.
- Design, manufacture and evaluate a representative ASIC.



# **DARE**

Design Against Radiation Effects (Digital) Cell Libraries



### Space ASICs in Europe: Old & Recent challenges

**LOW VOLUMES:** no big profits with space ASICs

**EXPENSIVE SPACE QUAL CONTROL** (rad effects, reliability make more design and tests necessary; Agencies periodic audits)

**PACKAGING:** still to be qualified for space: flip-chip and column/short pin packages for high pin counts. Also PCB mounting. Space ASICs tend to be large...

### **Big Uncertainties on EU ASIC Fabs future:**

- **ATMEL(F)** is selling its last plant in Europe (Rousset), after selling plants in France (MHS), UK and Germany. The whole ASIC Business Unit might be sold as well. Sales declines forced to temporary foundry shuts.
  - **E2V(F)** is restructuring internally due to revenue decline. Temporary shuts.
  - XFAB fab in UK closing
- **LFOUNDRY (D)** fab in Landshut is closed. Future of Rousset plant (see above) is uncertain.



### Why DARE was created

- late 90's ASIC Foundries used for space components were scarce, expensive and were discontinuing rad hard processes (ABB-HAFO & SOS). The dependence on commercial, high volume ASIC processes was evident.
- **1999:** First Technology Research Programme (TRP) funds were dedicated to Harden-by-Design ASIC libraries based on a commercial technology: UMC 180nm available on Europractice MPW.
- **2000**/**2001**After 1st proof of concept, new contracts launched to improve and add library elements, and develop a 1st customer design (DROM).
- **2006**/**07** new contracts launched to do a second customer design (LEON3), including ESCC evaluation and a maintenance contract, to start porting DARE to 90nm.



#### Closed:

• 14177/99/NL/FM GSTP-2 Proof of concept

• 14932/00/NL/DS NSGU Main Library Development

• 15852/01/NL/FM TRP Radiation Hardening by Design (RHBD) 3

### **On-going:**

• 19916/06/NL/JD GSTP ASICs for Space Fabricated with RHBD Library

• 20896/07/NL/JD TRP DARE Maintenance and Porting

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 TRP DARE+

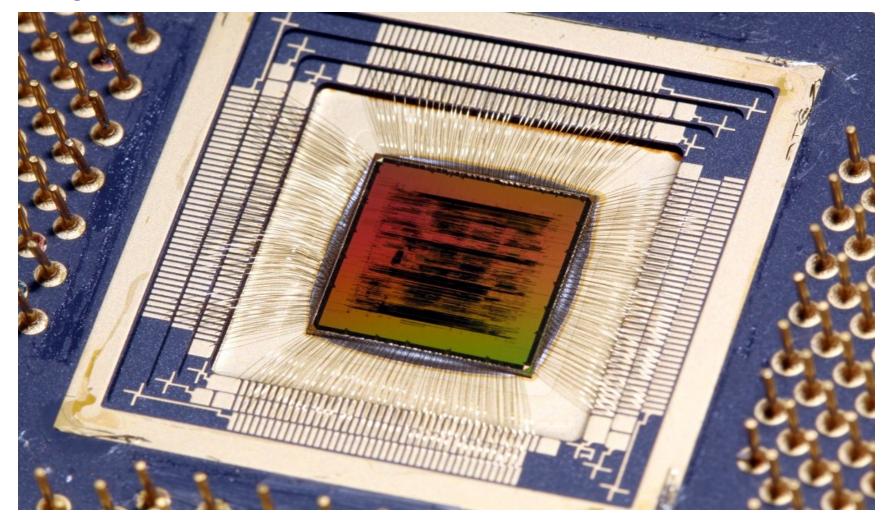
#### Related:

• 21855/09/NL/JK TRP Radiation Effects on Deep Sub Micron

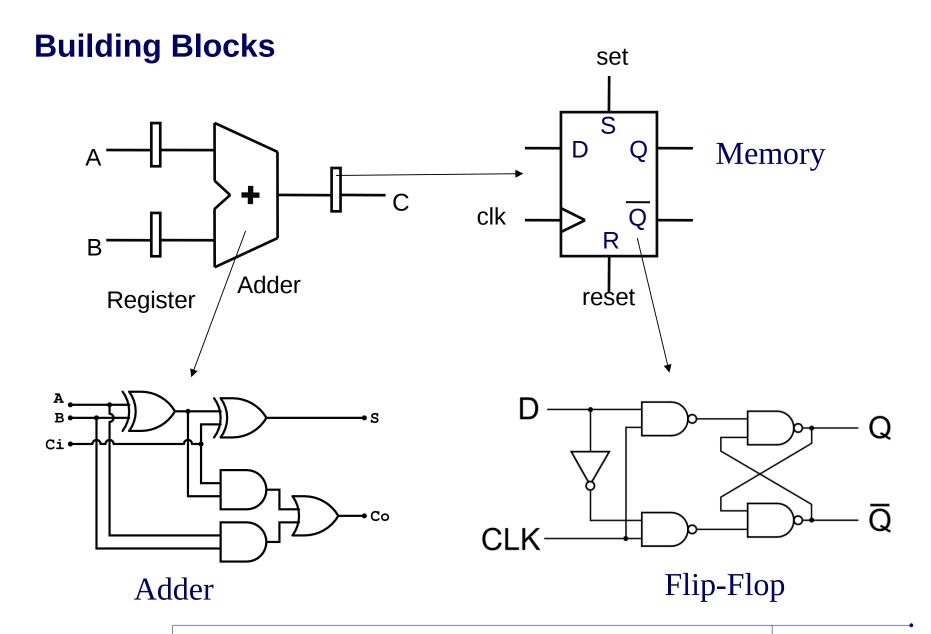
CMOS Technologies



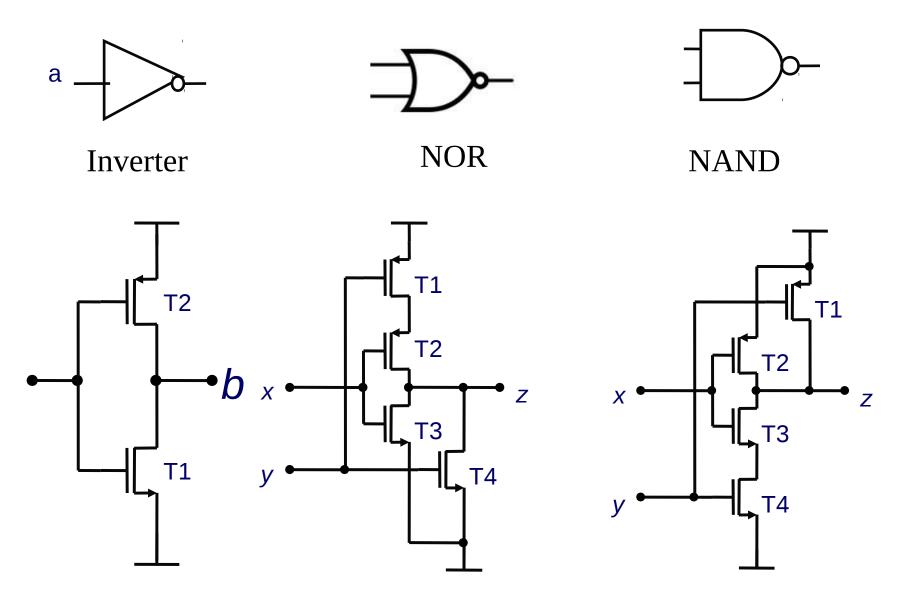
## **Integrated Circuits**





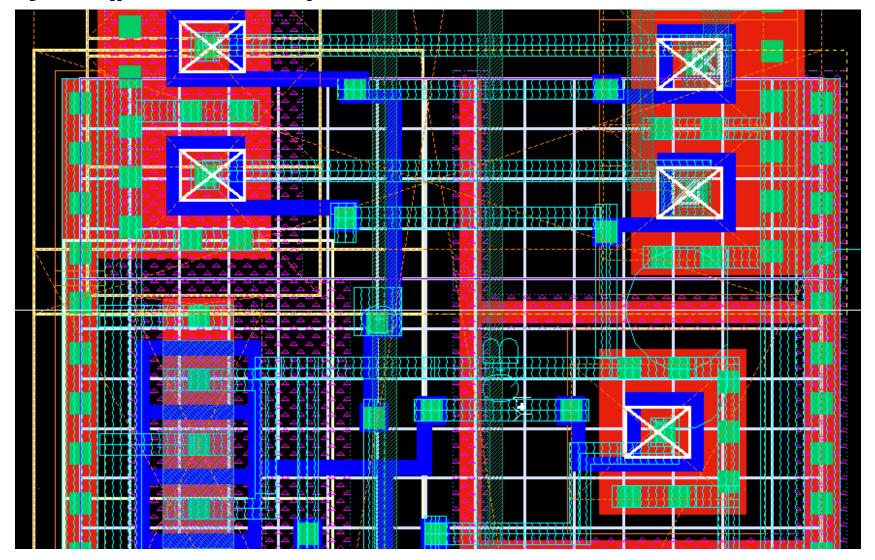




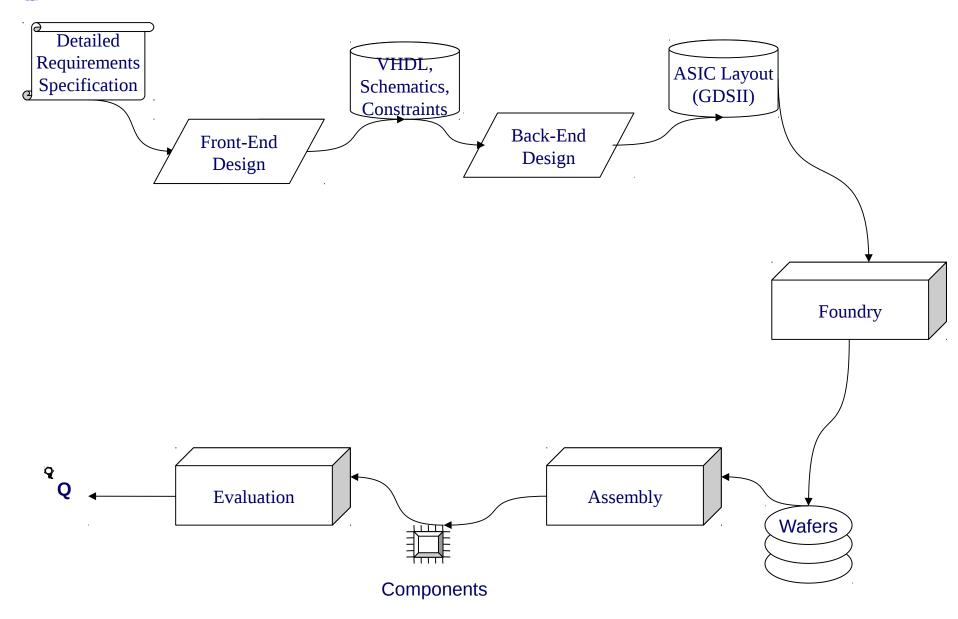


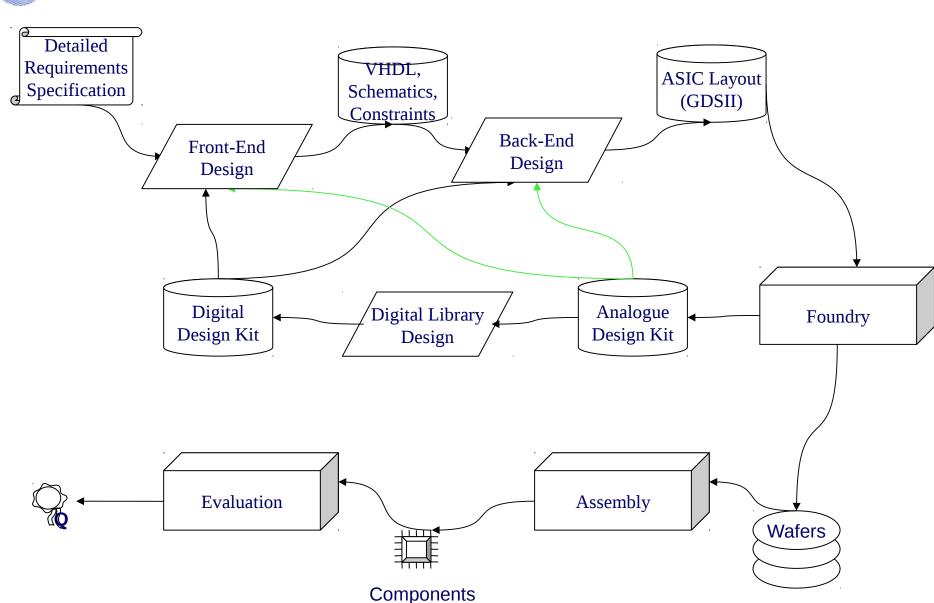


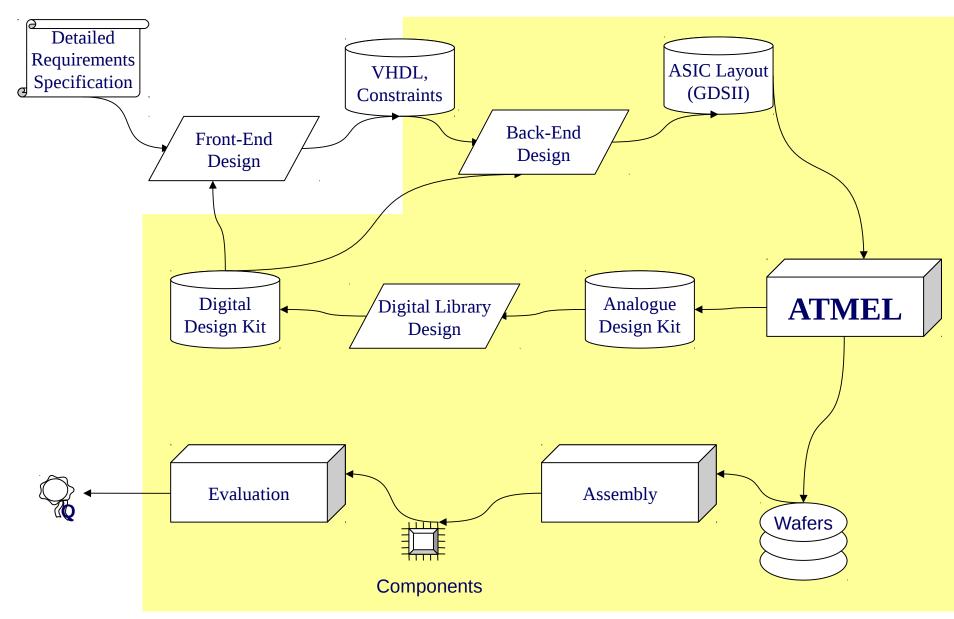
## **Layout (part of XDFF)**

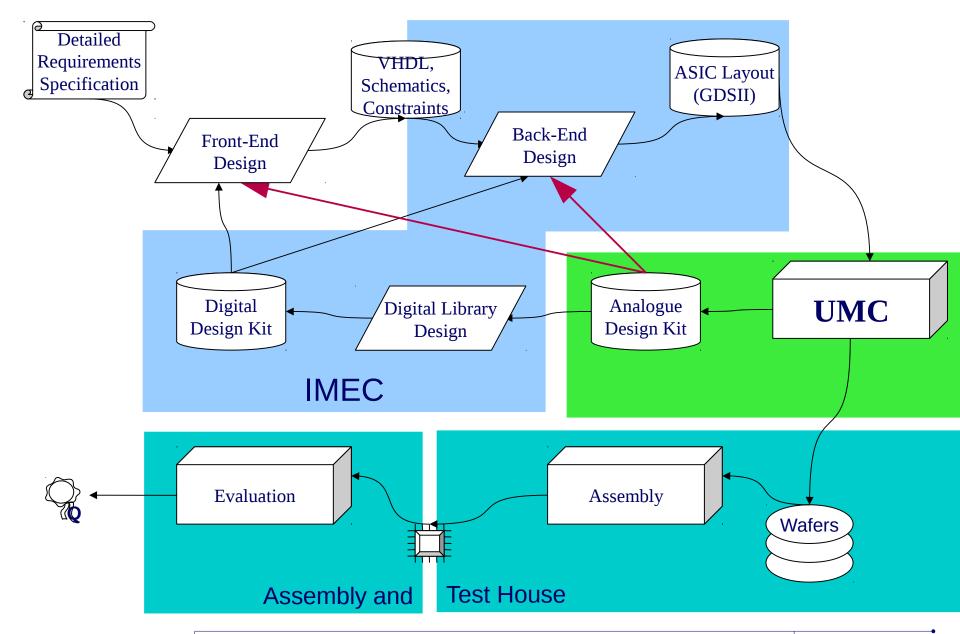


**DARE+** 











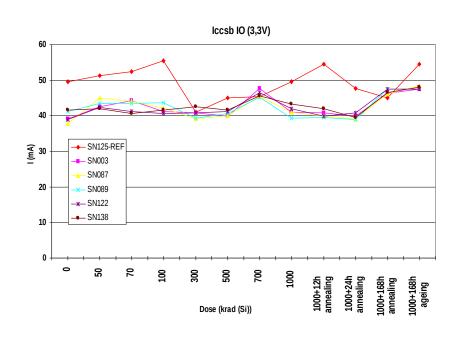
## **TID** test (1/2)

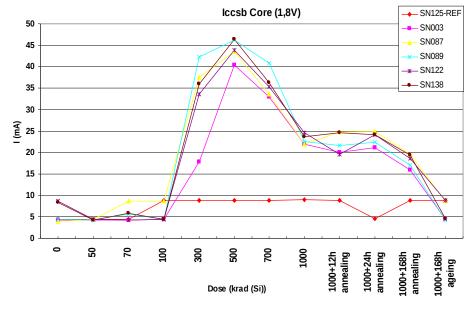
- Following ESCC22900
- Icc stand-by of the core : Stable until 100 krad(Si)

Increase until 500 krad (Si)

To decrease until 1 Mrad (Si)

Fully recovery & functional after accelerated ageing at 100 °C





#### • Icc stand-by of the IO:

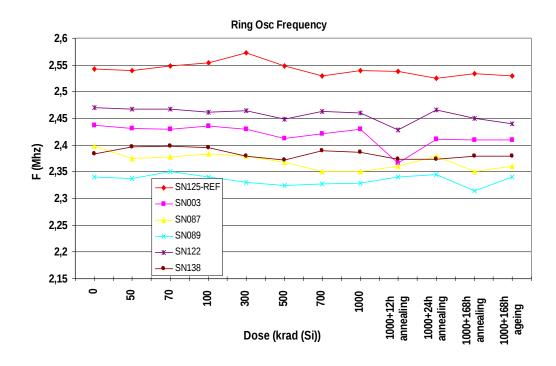
- Q Dominated by the LVDS buffers consumptions
- No significant evolution during the irradiation



## **TID test (2/2)**

Timing drift:
 Measure of an embedded ring oscillator
 No significant variations during and after irradiation







# DARE +

Design Against Radiation Effects (Digital) Cell Libraries for Harsh Space Environments



### **DARE+**

- Core Library
  - Clock gating
  - 3.3 V flavor
- RAM compiler
  - Problem fix
  - Dual port
- PLL
  - Full characterization
- Re-characterization for mixed-mode technology flavor

- I/O Library
  - 5V tolerant
  - Pull-up / pull-down
  - Improved LVDS
  - Improved ESD protection
  - Multi fan-out
  - IBIS Models
- 3.3 V -> 1.8 V voltage regulator
- Demonstration ASIC (DSP)



## **PLL**

Parameter	Min	Тур	Max	Unit
Junction Temperature	-55	-	145	°C
Supply Voltage	1.62	1.8	1.98	V
Power, Analog Supply	-	-	1	mA
Power, Digital Supply	-	-	0.5	mA
Input Frequency (1)	-	50	-	MHz
Output Frequencies (1) FX4 FX2 FX1	-	200 100 50	-	MHz
Duty Cycle; for all three outputs FX4, FX2, FX1	49	-	51	%
Phase Error	-100	-	100	pS
Cycle to Cycle Jitter	-100	-	100	pS
Long Term Jitter	-200	-	200	pS
Lock Time	-	25	100	μS
Output Load	-	-	0.8	pF



# SRAM (Compiler)

Parameter	Min	Тур	Max	Unit
Junction Temperature	-55	-	145	°C
Supply Voltage	1.62	1.8	1.98	V
SRAM Size	256	-	262144	bit
Operating Frequency	-	-	200	MHz



## 5V Tolerant I/O

	Cell Name Description		Pi	ns	
Cell Name			Enable	Output	PAD
	5V tolerant, 3.3V I/O				
BICM3V5VT4	5V tolerant, 3.3V CMOS/LVTTL Bi-directional pad, drive = 4 mA	A	EN	Z	Ю
BICM3V5VT8	5V tolerant, 3.3V CMOS/LVTTL Bi-directional pad, drive = 8 mA	A	EN	Z	Ю
BICM3V5VT12	5V tolerant, 3.3V CMOS/LVTTL Bi-directional pad, drive = 12 mA	A	EN	Z	Ю
BICM3V5VT16	5V tolerant, 3.3V CMOS/LVTTL Bi-directional pad, drive = 16 mA	A	EN	Z	Ю
BICM3V5VT24	5V tolerant, 3.3V CMOS/LVTTL Bi-directional pad, drive = 24 mA	A	EN	Z	Ю
ITTL3V5VT	5V tolerant, 3.3V CMOS/LVTTL input pad	A	EN	Z	Ю

Donomoton	Description	CMOS		LVTTL	
Parameter	Description	Min	Max	Min	Max
$V_{IL}$	Low-level input voltage		0.3*v33io		0.8 V
V <sub>IH</sub>	High-level input voltage	0.7*v33io		2 V	



## Output Pads w/ Slew Control

			Piı	ns	
Cell Name	Description	Input	Enable	Output	PAD
	3.3V I/O				
OCMTR4	3.3V Tri-state CMOS/LVTTL output pad, drive = 4 mA	A	EN		Z
OCMTR12	3.3V Tri-state CMOS/LVTTL output pad, drive = 12 mA	A	EN		Z
OCMTR24	3.3V Tri-state CMOS/LVTTL output pad, drive = 24 mA	A	EN		z
OCM3V4	3.3V CMOS/LVTTL output pad, drive = 4 mA	A			Z
OCM3V12	3.3V CMOS/LVTTL output pad, drive = 12 mA	A			Z
OCM3V24	3.3V CMOS/LVTTL output pad, drive = 24 mA	A			Z
BICM3V4	3.3V CMOS/LVTTL Bi-directional pad, drive = 4 mA	A	EN	z	Ю
BICM3V12	3.3V CMOS/LVTTL Bi-directional pad, drive = 12 mA	A	EN	z	Ю
BICM3V24	3.3V CMOS/LVTTL Bi-directional pad, drive = 24 mA	A	EN	z	Ю
	2.5V I/O				
OCM25VS	2.5 V CMOS output pad, Small drive	A			Z
OCM25VM	2.5 V CMOS output pad, Medium drive	A			Z
OCM25VL	2.5 V CMOS output pad, Large drive	Α			Z



## Output Pads w/ New Drive Strengths

	Jame Description		Pins		
Cell Name			Enable	Outpu t	PAD
	3.3V I/O				
OCMTR8	3.3V Tri-state CMOS/LVTTL output pad, drive = 8 mA	A	EN		Z
OCMTR16	OCMTR16 3.3V Tri-state CMOS/LVTTL output pad, drive = 16 mA		EN		Z

OCM3V8	3.3V CMOS/LVTTL output pad, drive = 8 mA	A			Z
OCM3V16	3.3V CMOS/LVTTL output pad, drive = 16 mA	A			Z
BICM3V8	3.3V CMOS/LVTTL Bi-directional pad, drive = 8 mA	A	EN	Z	Ю
BICM3V16	3.3V CMOS/LVTTL Bi-directional pad, drive = 16 mA	A	EN	Z	Ю



# Schmitt Trigger (2.5 / 3.3 V)

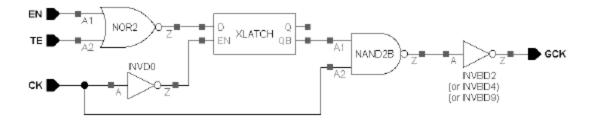
Symbol	Parameter	Condition	Minimum	Maximum
$V_{\mathrm{DD}}$	Supply Voltage	_	2.3V	2.7V
Vt+	Positive Going Threshold Voltage	$V_{OUT} \geq V_{OH(min)}$	0.9V	1.7V
Vt-	Negative Going Threshold Voltage	$V_{OUT} \leq V_{OL(max)}$	0.7V	1.5V
$\begin{array}{c} V_{hyst} \\ (\Delta V t) \end{array}$	Hysteresis Voltage	Vt+ - Vt-	0.2V	1.0V
V <sub>OH</sub>	Output High Voltage	$I_{OH} = -2 \text{ mA}$	V <sub>DD</sub> -0.45V	
V <sub>OL</sub>	Output Low Voltage	$I_{OL} = 2 \text{ mA}$		0.45V

Symbol	Parameter	Condition	Minimum	Maximum
$V_{\mathrm{DD}}$	Supply Voltage	_	3.0V	3.6V
Vt+	Positive Going Threshold Voltage	$V_{OUT} \! \geq V_{OH(min)}$	0.9V	2.1V
Vt-	Negative Going Threshold Voltage	$V_{OUT} \leq V_{OL(max)}$	0.7V	1.9V
$V_{hyst} \ (\Delta V t)$	Hysteresis Voltage	Vt+ - Vt-	0.2V	1.4V
V <sub>OH</sub>	Output High Voltage	$I_{OH}$ = -100 $\mu$ A $I_{OH}$ = -2 mA	V <sub>DD</sub> -0.2V 2.4V	
V <sub>OL</sub>	Output Low Voltage	$I_{OL} = 100 \mu A$ $I_{OL} = 2 \text{ mA}$		0.2V 0.4V



# Integrated Clock Gating

Cell Name	Drive Strength
XICGD2	2x standard drive
XICG <b>D4</b>	4x standard drive
XICGD9	9x standard drive





# Voltage Regulator

Parameter	Min	Тур	Max	Unit
Junction Temperature	-55	-	145	°C
Input Voltage Range	3.0	3.3	3.63	V
Output Voltage Range	1.62	1.8	1.98	V
Output Voltage Accuracy	-2		2	%
Output Current	-	-	50	mA
Virtually Zero I <sub>Q</sub> (Disabled)	-	-	50	nA
Very Low I <sub>Q</sub> (Enabled)	-	50	-	μА
PSRR @ 1KHz	-	50	-	dB
Start Up Time			100	μs



**LVDS** Receiver

**ESD Update** 

**IBIS** Models

**Dual Port SRAM Compiler** 

8ch Analogue Multiplexer



## Analogue Design Kit

- Layout PCell for ELT transistors
- LVS deck that recognizes ELT transistors and computes proper L and W
- An excel sheet to compute W/L given ELT layout dimensions

### Further development will target:

- Cleaned-up the SKILL code (sklint)
- Support for custom symbol (CDF) with TID parameter for simulation
- Support for LVT transistors



## Test Vehicles (1/2)

### (1) Analogue Characterization

Contains active and passive devices for characterization, including radiation tolerance

### (2) Digital Characterization

Contains all new or modified digital cell elements for (re-) characterization, including radiation tolerance



### Devices Test Vehicle

1.8V nmos N\_18\_MM, N\_LV\_18\_MM, N\_BPW\_18\_MM

1.8V pmos P\_18\_MM, P\_18\_LV\_MM

3.3V nmos N\_33\_MM, N\_BPW\_33\_MM

3.3V pmos P\_33\_MM

Bipolar PNP\_V50X50\_MM, PNP\_V100X100\_MM

Diodes DION\_MM, DIOP\_MM, DIONW\_MM

#### MOS transistor parameters:

- · Threshold voltage shift
- · Mismatch/offset voltage
- Leakage current
- Noise
- Mobility (max frequency)
- Breakdown voltage

#### Bipolar transistor parameters:

- Beta
- Noise
- Collector-Base leakage current
- Mismatch/offset voltage
- Transit time (max frequency)

#### Diode parameters:

- Reverse current
- · Ideality factor
- · Barrier potential



# Library Test Vehicle

Library element	Core area (µm²)	I/O pins
CORE (ICG, SETfilter,)	500000	20
LVDS	0	22
I/O (functional/drive strength/IBIS)	0	50
I/O ESD (old + new)	0	20
Single Port sram128wx128b	702432	12
Single Port sram512wx64b	1209369	12
Single Port sram1024wx40b	1491200	12
Single Port sram1024wx16b	667440	12
Dual Port sram64wx16b	167384	12
PLL	0	23
Linear Voltage Regulator (3.3V → 1.8V)	2000000	10
Switched Voltage Regulator (3.3V → 1.8V)	5000000	10
reference circuits (UMC RO, single		
transistors, ELT/non-ELT)	100000	20
TID structures (ELT/GB variants, 128bit		
registers)	200000	20
SEE structures (SET filters, ROs, pulse		
propagation)	200000	20
SRAM subcells (MEM cells, timing		
measurement, small matrices with direct		
write/read access)	1000000	20
PLL subcells (VCO, divider, PFD)	100000	10
Voltage Regulator subcells (bandgap,		
comparator, switch, thermal diode)	2000000	20

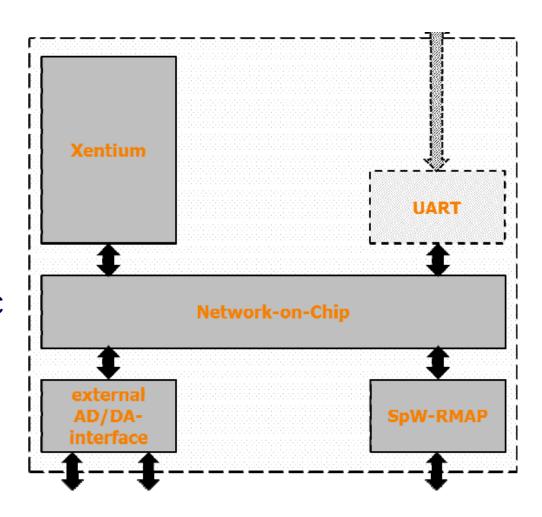


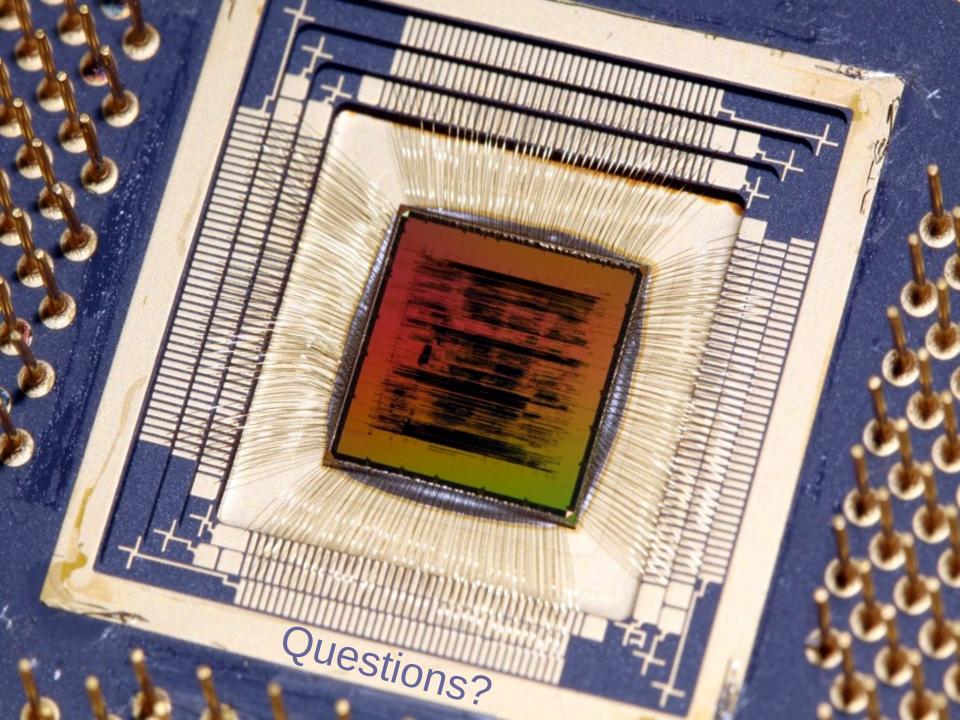
### Test Vehicles (2/2)

### (3) DSP

- Xentium VLIW DSP Core
- Network on chip
- SpaceWire I/F w/ RMAP
- Bridges for external ADC/DAC

Demonstration of Development Flow and tool compatibility







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